

1. A diffractive optical element having a design wavelength  $\lambda$ , comprising:

a mark shaped so that, with regard to the predetermined light, a phase difference corresponding to a multiple, by an integer, of the design wavelength  $\lambda$  is produced between (i) a light ray, of the predetermined light, as transmitted through or reflected by the mark and (ii) a light ray, of the predetermined light, as transmitted through or reflected by a portion adjacent to the mark, and that,

15 with regard to second light of a second wavelength  $\lambda'$   
different from the design wavelength  $\lambda$ , no phase  
difference corresponding to a multiple, by an integer,  
of the second wavelength  $\lambda'$  is produced between (a) a  
light ray, of the second light, as transmitted through  
20 or reflected by the mark and (b) a light ray, of the  
second light, as transmitted through or reflected by a  
portion adjacent to the mark.

2. A diffractive optical element according to  
25 Claim 1, wherein the mark is placed at or adjacent a  
center of the diffractive surface and is defined by a  
recess formed on the diffractive surface, and wherein

the recess is formed with a depth effective to assure that a phase difference corresponding to a multiple, by an integer, of the design wavelength  $\lambda$  is produced between (i) a light ray, of the predetermined light, as transmitted through or reflected by the mark and (ii) a light ray, of the predetermined light, as transmitted through or reflected by a portion adjacent to the mark, and that no phase difference corresponding to a multiple, by an integer, of the second wavelength  $\lambda'$  is produced between (a) a light ray, of the second light, as transmitted through or reflected by the mark and (b) a light ray, of the second light, as transmitted through or reflected by a portion adjacent to the mark.

3. A diffractive optical element according to Claim 1, wherein the mark is placed at or adjacent a center of the diffractive surface and is defined by a protrusion formed on the diffractive surface, and wherein the protrusion is formed with a height effective to assure that a phase difference corresponding to a multiple, by an integer, of the design wavelength  $\lambda$  is produced between (i) a light ray, of the predetermined light, as transmitted through or reflected by the mark and (ii) a light ray, of the predetermined light, as transmitted through or reflected by a portion adjacent to the mark, and that

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no phase difference corresponding to a multiple, by an integer, of the second wavelength  $\lambda'$  is produced between (a) a light ray, of the second light, as transmitted through or reflected by the mark and (b) a  
5 light ray, of the second light, as transmitted through or reflected by a portion adjacent to the mark.

10 4. A diffractive optical element according to Claim 1, wherein the diffractive surface and the mark are adapted to transmit light rays of the wavelengths  $\lambda$  and  $\lambda'$ .

15 5. A diffractive optical element according to Claim 1, wherein the diffractive surface and the mark are adapted to reflect light rays of the wavelengths  $\lambda$  and  $\lambda'$ .

20 6. A diffractive optical element according to Claim 1, wherein the diffractive surface comprises a binary optics, and wherein the diffractive surface and the mark are formed in accordance with a lithographic process.

25 7. A diffractive optical element according to Claim 1, further comprising a substrate on which the diffractive surface and the mark are formed, and a metal ring for holding the substrate.

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8. A diffractive optical element according to Claim 1, further comprising a metal ring, wherein the mark is placed at a center of the diffractive surface, and wherein the mark is disposed at a central position of an outside circumference of the metal ring.

9. A diffractive optical element according to Claim 8, wherein the mark and the central position of the metal ring are registered with each other, on the basis of detection of the mark by use of the second light of the second wavelength  $\lambda'$ .

10. A projection optical system including a diffractive optical element as recited in any one of Claims 1 - 9.

11. A projection exposure apparatus for projecting a pattern onto a substrate by use of a projection optical system as recited in Claim 10.

12. A device manufacturing method, comprising the steps of:

exposing a substrate with a device pattern by use of an exposure apparatus as recited in Claim 11; and developing the exposed substrate.